CLAIMS

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What is claimed is.

1. A method of classifying particles, comprising
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placing a fluid into a device, wherein the fluid contains at least two particle types, and wherein the device includes a first electrode, a second electrode, a third electrode, and a conduit disposed between the second electrode and the third electrode;

first biasing between the second electrode and the third electrode under conditions to focus a first particle type; and

nth biasing between the second electrode and the third electrode under conditions to focus an nth particle type.

- 2. The method according to claim 1, wherein first biasing under conditions to focus a first particle type includes a first particle type that includes a first plurality of particle types.
- 3. The method according to claim 1, wherein first biasing under conditions to focus a first particle type includes a first particle type that includes a first plurality of particle types, and following nth biasing, further including:
- n+1st biasing between the second electrode and the third electrode under conditions to focus an n+1st particle type.

- The method according to claim 3, wherein n+1st biasing under conditions to focus
- a first particle type includes an n+1st particle type that includes an n+1st plurality of particle
- 3 types.

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- The method according to claim 1, further including:
- establishing a convective force in the fluid, wherein the convective force directs the fluid
- 3 into the conduit.
 - 6. The method according to claim 1, further including:

establishing a convective force in the fluid, wherein the convective force directs the fluid into the conduit, wherein the conditions to focus a particle type include an electrophoretic mobility for a given particle type that overcomes the convective force in the conduit, and wherein the particle type focuses at the second electrode.

- 7. The method according to claim 1, wherein the first electrode includes a ground, wherein the second electrode includes a varactor, and wherein the third electrode includes a varactor.
- 8. The method according to claim 1, wherein the fluid is pH-buffered.
- The method according to claim 1, wherein the at least two particle types include a
- 2 plurality of zwitterion molecules.

1	10.	The method according to claim 1, after first biasing, further including:
2		second biasing between the second and third electrodes under conditions to
3	separa	te a second particle type from the fluid.
1	. 11.	The method according to claim 1, after at least one of first biasing and Nth
2	biasing, further	er including:
3		analyzing at least one of the first particle type and the Nth particle type by a
4	method selected from quantitative analysis, qualitiative analysis, and a combination	
5	thereof.	
	12.	The method according to claim 1, wherein the device further includes: a fluid source reservoir into which is disposed the first electrode; a fluid receptacle reservoir into which is disposed the third electrode; and wherein the conduit communicates between the fluid source reservoir and the receptacle reservoir.
1	13.	A device, comprising:
2		a conduit disposed in a dielectric structure;
3		a fluid source reservoir disposed at a first end of the conduit;
4		a fluid receptacle reservoir disposed at a second end of the conduit;
5		an optional first electrode disposed in the fluid source reservoir and spaced apart

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from the first end of the conduit;

7		a second electrode spaced apart from the first electrode and disposed either in the	
8	fluid source reservoir proximate the conduit, or in the conduit proximate the fluid source		
9	reservoir;		
10		a third electrode disposed in the fluid receptacle reservoir and space apart from	
11	the second end of the conduit.		
1	14.	The device according to claim 13, further including:	
2		a fluid-moving device connected to the device.	
1	15.	The device according to claim 13, wherein the dielectric includes:	
1 2 3		a first layer including a channel disposed therein; and	
3		a second layer disposed above the first layer.	
_		my 1:	
	16.	The device according to claim 13, wherein the conduit includes a liner that resists	
1 2	electroosmos	1S.	
1	17.	The device according to claim 13, wherein the conduit includes a hydroxypropyl	
2	methyl cellulose liner.		
1	18.	A system for classifying at least two charged particle types comprising:	
2		a device, including:	
3		a conduit disposed in a dielectric structure;	
4		a fluid source reservoir disposed at a first end of the conduit;	

5	a fluid receptacle reservoir disposed at a second end of the conduit;
6	an optional first electrode disposed in the fluid source reservoir and spaced
7	apart from the first end of the conduit;
8	a second electrode spaced apart from the first electrode and disposed
9	either in the fluid source reservoir proximate the conduit, or in the conduit
10	proximate the fluid source reservoir;
11	a third electrode disposed in the fluid receptacle reservoir and space apart
12	from the second end of the conduit;
13	a fluid containing the at least two charged particle types, wherein the fluid is pH
14	buffered, and wherein the fluid is disposed in the fluid source reservoir;
14 15 16	a blank fluid disposed in the conduit and in the fluid receptacle reservoir; and
1 6	a fluid mover for creating a convective force in the conduit.
or of the control of	
1	19. The system according to claim 18, wherein the at least two charged particle types
1 2	include at least two zwitterions.
1	20. The system according to claim 18, wherein the at least two charged particle types
2	include at least two mammalian body serum particle types.

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from an inorganic dielectric, an organic dielectric, and a semiconductive dielectric.

The system according to claim 18, wherein the dielectric structure is selected

1	22. A p	rocess of making a particle classifier comprising:
2		forming a conduit including a first end and a second end in a dielectric structure;
3		forming a first fluid source reservoir at the first end;
4		forming a first fluid receptacle reservoir at the second end;
5		forming an optional first electrode in the first fluid source reservoir and spaced
6	apa	rt from the first end;
7		forming a second electrode either in the first fluid source reservoir proximate the
8	con	duit, or in the conduit proximate the first fluid source reservoir;
9		forming a third electrode in the first fluid receptacle reservoir and spaced apart
	fro	m the second end.
1 1 2 3 4 4 4 4 4 4 4 4 4 4 4 4 4 4 4 4 4 4	23.	The process according to claim 22, wherein forming a conduit includes: etching a channel in a first substrate; covering the first substrate with a second substrate; and optionally treating the channel with a neutralizing process.
1	24.	The process according to claim 22, wherein forming a conduit includes:
2		etching a channel in a first substrate;
3		covering the first substrate with a second substrate; and
4		optionally treating the channel with a neutralizing process; and further including:
5		etching the first fluid source reservoir and the first fluid receptacle reservoir
6	thr	rough second substrate;

7		forming the second electrode by deposition in the first fluid source reservoir and
8	upon t	he second substrate; and
9		optionally forming the third electrode by deposition in the first fluid receptacle
.0	reservoir and upon the second substrate.	
1	25.	The process according to claim 22, further including:
2		forming a second fluid source reservoir;
3		forming a second fluid receptacle reservoir;

forming a fourth electrode in the second fluid source reservoir; and

forming a fifth electrode in the second fluid receptacle reservoir.